

# UGPCB Metal Substrate Product Introduction

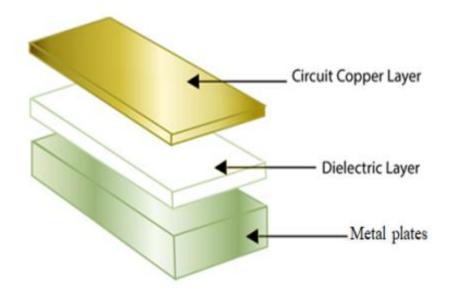
2025-4



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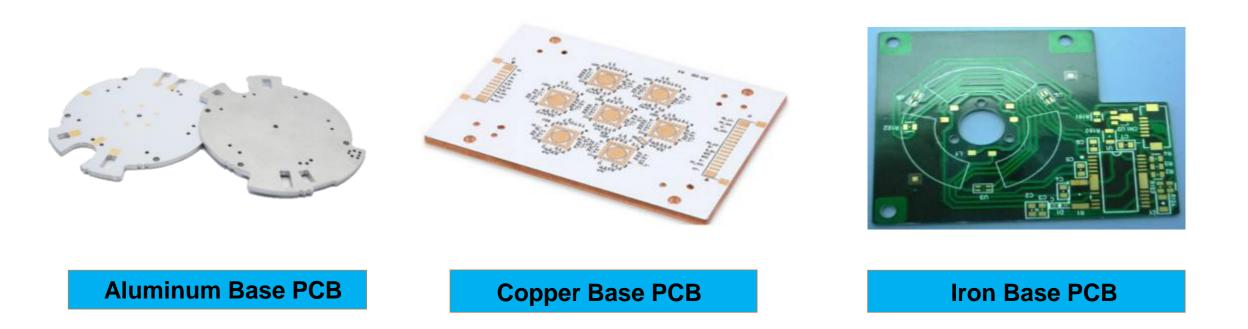




- > **Definition**
- A metal substrate is a type of copper-clad laminate with good thermal dissipation capabilities. Generally, a single-sided board consists of three layers: the circuit layer (copper foil), the dielectric layer, and the metal base layer.



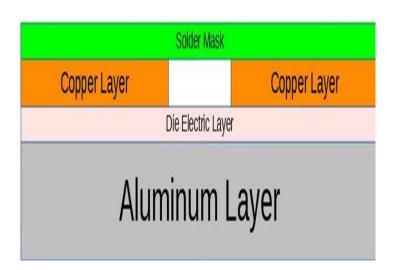
#### 1) According to different types of metal substrates, the commonly used ones are:



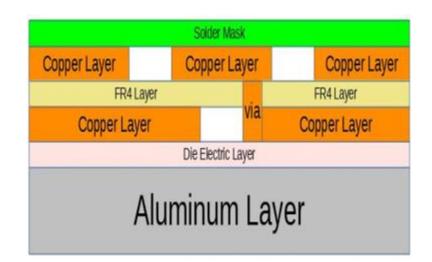


#### 2) Based on the number of layers:

#### Single Sided Metal Base PCB



#### 2-layer Metal base PCB



## **3. Introduction to Parameters of Aluminum PCB**



## 1) Shengyi SAR20H datasheet:

#### SAR20H

#### Aluminium Base Laminate

#### **FEATURES**

#### • High CTI

- Halogen free
- Superior heat dissipation
- Excellent mechanical process ability
- Excellent thermal and insulation reliability

#### **GENERAL PROPERTIES**

Test Items	Test Method	Test Condition	Unit	Typical Value
Thermal Conductivity	ASTM-D5470	Dielectric layer	W/(m·K)	2.1
Thermal Resistance	ASTM-D5470	Dielectric layer	K⋅cm²/W	0.52
Tg	IPC-TM-650 2.4.25D	DSC	°C	160
Td	IPC-TM-650 2.4.24.6	TGA (5% W.L)	°C	395
Thermal Stress	IPC-TM-650 2.4.13.1	288℃, float	min	30
	IPC-TM-650 2.4.24	Before Tg	ppm/°C	17
CTE (Z-axis)	IPC-TM-650 2.4.24	After Tg	ppm/°C	39
	IPC-TM-650 2.4.24	<b>50-260</b> ℃	%	0.69
Volume Resistivity	IPC-TM-650 2.5.17.1	C-96/35/90	MΩ-cm	10 <sup>8</sup>
Surface Resistivity	IPC-TM-650 2.5.17.1	C-96/35/90	MΩ	10 <sup>8</sup>
Dielectric Breakdown	IPC-TM-650 2.5.6	D-48/50+D-0.5/23	kV	5.0
Hi-pot Test	GB/T-31988	DC	V	4000
ni-pot test	GD/1-51900	AC	V	3000
Peel Strength (1oz)	IPC-TM-650 2.4.8	288°C/10s	N/mm [lb/in]	1.3 [7.43]
Flammability	UL94	C-48/23/50	Rating	V-0
MOT	UL	Α	°C	130
CTI	IEC60112	Α	Rating	PLC 0

**APPLICATIONS** 

On-board Charger, EPS, Automobile Lighting, AC-Inverter, DC-DC Convertor Power Supply Board Hi-power LED lighting

Remarks: 1. Typical value is based on specimen of 1.5mm Al/100um dielectric/1oz Cu.

 All the typical value listed above is for your reference only, please turn to Shengyi Technology Co., Ltd. for detailed information, and all rights from this data sheet are reserved by Shengyi Technology Co., Ltd.

#### PURCHASING INFORMATION

	Material	Thickness			
Cu	E/D Cu	Hoz-4oz			
Dielectric Layer	Epoxy resin filled with inorganic filler	50-150um			
Aluminium Plate	5052 Al	0.3-3.0mm			
Protective Film	PET				
Standard Size	tandard Size 1040mm×1240, 510mm×610mm				

Remarks: Other sheet size and thickness could be available upon request.

## **3. Introduction to Parameters of Aluminum PCB**



## 2) Introduction to Parameters of Aluminum PCB

ITEMS	Definition								
TG	The temperature at which the glassy state transitions to the rubbery state (or high-elastic state) is called TG. (Glass transition temperature)	normal TG		mi	mid TG			high tg	
		110-150		150	)-170		>17	70	
TD	When the PCB is heated to a temperature at which its mass decreases by 5%, this temperature is referred to as the pyrolysis temperature of the PCB. (thermaldecomposition temperature)	normal			mid		high		
	pyrolysis temperature of the reb. (thermalaecomposition temperature)	>31	0		>325		>340		
СТІ	The highest voltage value that the material surface can withstand without forming leakage traces when subjected to 50 drops of electrolyte (0.1% ammonium chloride aqueous solution) is called the Comparative Tracking Index (CTI).	СТІ	≧600	400- 600	250- 400	175- 250	100- 175	0-100	
Ch	The CTI test is specifically for the PCB surface, and it refers to the ability of the PCB to resist contamination in the environment.		0	1	2	3	4	5	
		IEC	I	Ш		IIIA	IIIB		
мот	The maximum allowable operating temperature (which is the highest temperature guaranteed by UL for material usage, in degrees Celsius).								
Thermal Conductivity		nder The thermal conductivity depends on the formulation of the thermal conductive adhesive (type of filler, particle size, and specific gravity).				ctive			
Thermal Impedance	When heat is transferred within an object through thermal conduction, the resistance encountered is called thermal resistance. Unit: °C*in²/W (the temperature rise per 1W of power dissipated).	Influencing factors: the formula and thickness of the thermally conductive adhesive film.					adhesive		
Dielectric breakdown	Based on the requirements of UL and IEC for various electrical safety standards, products must undergo a withstand voltage test. The insulation strength of the substrate directly affects the test results. Under certain conditions, the voltage applied to the specimen is gradually increased according to regulations until the specimen breaks down, thereby determining the breakdown electric field strength of the specimen.	The breakdown of insulating materials can be categorized into electrical breakdown, and electrochemical breakdown. There will be certain of in the actual measurement results. The thickness of the material and the co cladding affect the heat dissipation efficiency, thus resulting in different br voltages. The higher the glass transition temperature (TG), the more difficut thermal breakdown carbonization to occur, and the stronger the voltage withstand capability. Glass fiber has a stronger voltage withstand capability.			differences pper eakdown It it is for ithstand d to epoxy				

## **3. Introduction to Parameters of Aluminum PCB**

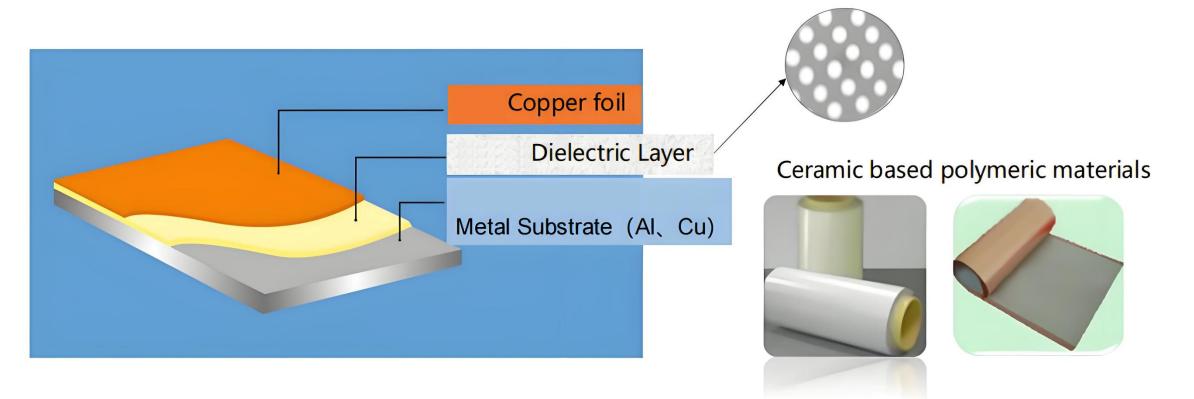


## 2) Introduction to Parameters of Aluminum PCB

ITEMS		Defir	nition	Remark	
DK	field, it generates ir the electric field. Th electric field (in a va	placed in an external nduced charges that w ne ratio of the original acuum) to the final ele is the dielectric consta	eaken external ctric	The primary factors influencing the DK value (Dielectric Constant) in PCB materials include <b>Fiberglass Cloth</b> , <b>Resin</b> , and <b>Filler</b> .	
Flammability	Flammability Rating				
peel Strength	Peel strength - refe substrate.	rs to the adhesion be	etween the copper fo	oil and the	
Volume/surface resistance	Volume resistance surface resistance				What is reflected is the insulation quality of the PCB.
Hi-pot Withstand	Copper clad laminate manufacturers perform high-voltage testing before shipment.				Mainly detect the quality of the insulation layer (impurities, cracks, etc.) of aluminum-based copper clad laminates.
CTE		ermal expansion (CTE) instability due to expan			The aluminum base plate mainly refers to the adhesive film layer in the middle, which is the insulating layer.
Thermal stress	Immersion tin test at	the condition of 288°C	2		
	ITEMS	normal	mid		
T300/T288/T260	T260	30	30	30	
Thermal Crack	T288	5	5	15	
Resistance Time	Т300	-	-	2	



#### 3) Introduction to the material of the insulation layer on the aluminum substrate:



The insulating layer (thermal conductive adhesive film) not only serves to conduct heat and bond materials (specifically, aluminum plates and copper foil), but also acts as the dielectric material ensuring electrical insulation between the wiring layer and the aluminum base. Consequently, within the entire aluminum substrate, the insulating layer is the most crucial component, as it determines the thermal conductivity and the dielectric strength of the aluminum substrate. Compared to traditional FR-4 materials (with a thermal conductivity of 0.3-0.5 W/m•K), its thermal conductivity is more than three times higher.



#### 3) Introduction to the Material of the Insulation Layer on Aluminum Substrates:

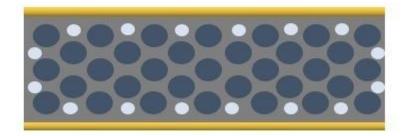
What are the factors that affect the thermal conductivity coefficient of insulating layer of aluminum substrate?

#### 1. Types of fillers

Types of fillers	Thermal conductivity (W / m * K)	Breaking through voltage
Al <sub>2</sub> O <sub>3</sub>	25~40	+ +
MgO	25~50	+
SiO <sub>2</sub>	9.6	+
Si <sub>3</sub> N <sub>4</sub>	50	( <b>.</b>
BeO	270 -	
SiC	25~100	
AIN	120~220	+
BN	100~250	+

NOTE: + GOOD - Bad.

#### 2. Fill particle size and weight

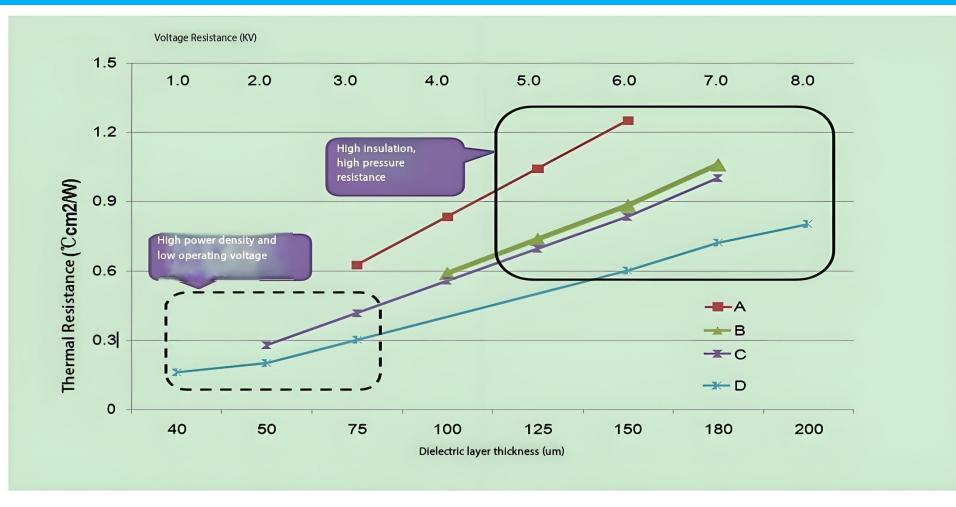


The way and weight of the thermal conductive material is also an effective way to effectively improve the thermal carrying capacity of the insulation layer.

The most commonly used type of thermally conductive filling for metal-based copper plating is alumina, as can be seen from the characteristics table of different types of filling above. Different fillers have a great influence on the thermal conductivity and pressure resistance of the insulation layer, and at the same time, the filling mode and weight of the thermally conductive material also have a large influence on the conductivity and the pressure resistance.



#### 3) Introduction to the Material of the Insulation Layer on Aluminum Substrates:



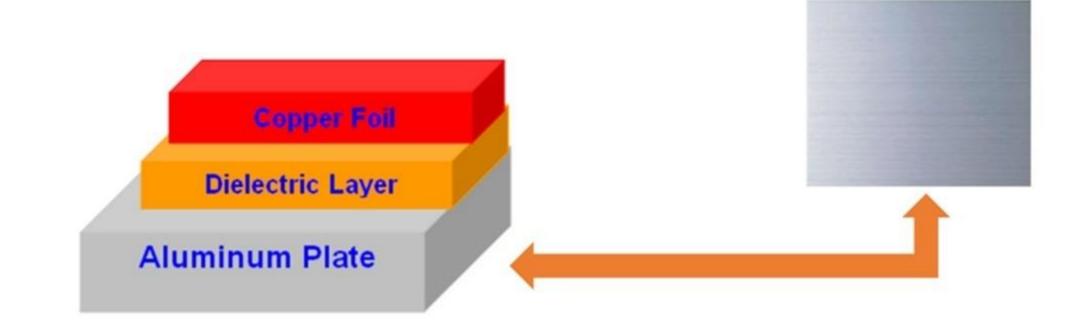
#### Same material:

Throughput Voltage: The piercing voltage is directly proportional to the thickness of the insulation layer. The thicker the insulation, the stronger the resistance to piercing Voltage.

Heat resistance: Heat resistance is also directly proportional to the thickness of the insulation layer, the thicker the insulation, the greater the thermal resistance and the worse the thermal conductivity.



## 4) Aluminum Material Introduction:

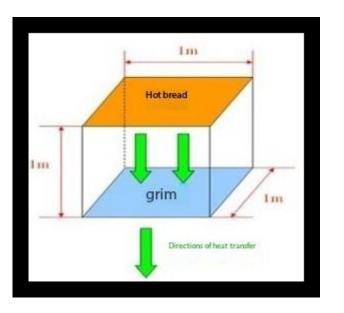


Aluminum not only plays the role of heat conduction in the aluminum substrate, but also the rigid support of the entire PCB.

Different aluminum materials have different physical properties and applications, commonly used in the PCB industry aluminum 1xxx, 3xxx, 5xxx, 6xxx. Among them, 1xxx aluminum is mainly used in the lighting industry, belonging to low-cost materials, industrial power supplies or other high-end products are mainly 5xxx aluminum and 6xxx aluminum.



## 5) Introduction to the Thermal Conductivity:



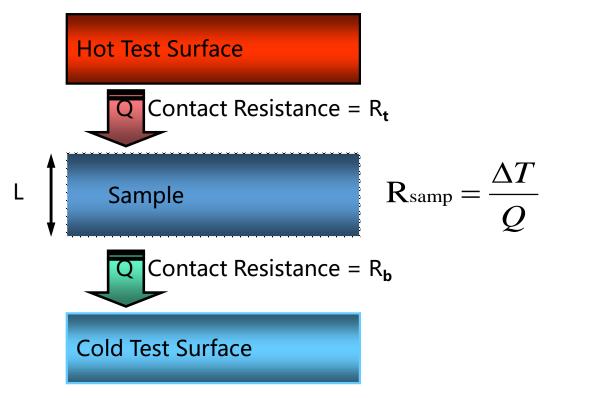
Test Method	Name
D5470	Thermal resistance method
E1461	Laser Method
ISO-22007	Flat plate method

- The thermal conductivity refers to the amount of heat transmitted through 1 square meter of material, 1 meter thick, with a temperature difference of 1 degree (K, °C) between the two surfaces, within 1 hour under steady-state heat transfer conditions. The unit is watts per meter per degree (W/(m•K), where K can be replaced by °C).
- Currently, there are three commonly used testing methods in the industry: the heat flow meter method, the laser flash method, and the guarded hot plate method. These three testing methods have different principles and can result in varying test outcomes.



## 5) Introduction to the Thermal Conductivity:

Introduction to the Testing Principle of D5470 - Heat Resistance Method



Thermal Conductivity Equation  $k_{actual} = \frac{L}{A * R_{samp}}$ 

\* The calculated thermal conductivity is the true thermal conductivity of the material only when the contact thermal resistances Rt and Rb are 0.
\* Sources of contact thermal resistance:

① Surface contamination of the test sample
② Uneven surface of the test sample
③ Large surface roughness of the sample

The ASTM-D5470 standard by the American Society for Testing and Materials (ASTM) is designed for testing the thermal conductivity of electrical insulating materials, and it is currently the most recognized method in the industry for measuring the thermal conductivity coefficient of aluminum substrates. The testing procedure involves applying a constant heat flow to the aluminum substrate so that the heat flows perpendicularly through it, with no lateral heat diffusion. The temperatures on the upper and lower surfaces of the aluminum substrate are measured, and then the thermal conductivity coefficient of the aluminum substrate is calculated.



## 5) Introduction to the Thermal Conductivity:



Introduction to the Testing Principle of E1461 Laser Method

# $\lambda(T) = \alpha(T) \stackrel{*}{\sim} Cp(T) \stackrel{*}{\sim} \rho(T)$

- A laser beam is directed at the top surface of the sample, and an infrared detector measures the temperature change on the bottom surface. The actual data measured is the thermal diffusivity of the sample. By comparing it with a standard sample, the density and specific heat of the sample are also obtained (or the specific heat obtained by other testing methods). The thermal conductivity of the sample is then calculated.
- > The advantages are its speed, non-contact nature, and suitability for high-temperature, high-thermal-conductivity samples.



#### 5) Introduction to the Thermal Conductivity:



#### Introduction to the Testing Principle of the ISO-22007 Flat Plate Method

The high accuracy of this method depends on

- Unique probes
- Innovative mathematical models
- Specialized electronic data acquisition systems
- Utilizing a thermally resistive material [nickel] as the probe, which also serves as both a heat source and a temperature sensor. The thermal resistance coefficient of nickel—the relationship between temperature and resistance—is linear, meaning that changes in resistance can indicate heat loss, thereby reflecting the thermal conductivity of the sample.
- In the test, the probe is placed between two samples for testing. When current passes through the nickel, its temperature rises, and the generated heat spreads to the samples on both sides of the probe. The speed of this thermal diffusion depends on the thermal conductivity characteristics of the material. By recording the temperature and the response time of the probe, the thermal conductivity coefficient of the material can be calculated.



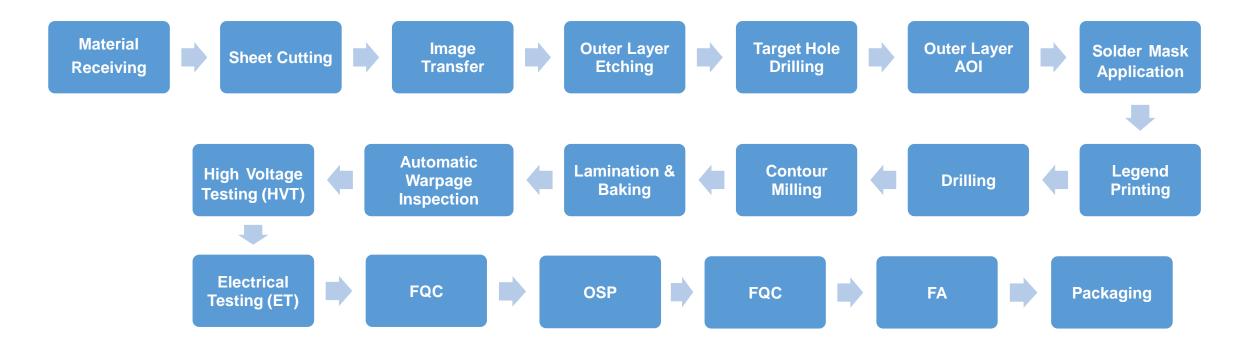
### 5) Introduction to the Thermal Conductivity:

Comparison of test data from different testing methods

	Thermal Conductivity (W/m·K)						
	Test Metho	d	ASTM E1461	ASTM E1461 IS022007-2			
	Specimen Size(	mm)	10×10	80×80	25.4×25.4		
	Specimen	Thk(mm)	<b>60</b> °C	<b>25</b> ℃	<b>60</b> ℃		
A1	Film	0.213	1.376	1.942	1.321		
A2	AI CCL	1.114	42.14	122.6	8.098		
B1	Film	0.152	1.237	2.319	1.212		
B2	AI CCL	1.067	46.11	120.8	8.736		
С	CEM-3	1.552	0.921	Δ	0.803		
D	Thermal FR-4	1.505	1.180	Δ	0.910		
Е	Normal FR-4	1.522	0.403	Δ	0.386		
	Remark		△-The samples are too t be measured by the test		perature is too high to		

Remark: Above data is the test result for reference only.





Unlike traditional FR-4, the main component of aluminum boards is aluminum. Therefore, the biggest difference in the processing of aluminum PCBs compared to traditional non-metallic PCBs lies in the mechanical processing steps (drilling & shaping). The mechanical processing of aluminum boards requires different equipment and tools than those used for traditional PCBs.

# Introduction to UGPCB Metal Substrate Capabilities



No	Itom	MCPCB Capability				
No.	ltem	Mass Production	Sample/Development			
1	Layer Count	1-2L	1-4L			
2	Laminate Supplier	Shengyi,Ventec, Boyu, Wazam, Doosan	Shengyi,Ventec, Boyu, Wazam, Doosan			
3	Metal Substrate Type	Al Base, Cu Base	Al Base, Cu Base			
4	Laminate Type	AL:SY SAR20H, SY SAR10S,Wazam HA88- T3, Boyu AL-01-B 20H , DOOS: DST-7000S Cu:SY SCR20S, VT-4B3, VT-4B3C, DOOS: DST-7000S	AL:SY SAR20H, SY SAR10S,Wazam HA88- T3, Boyu AL-01-B 20H, VT-4B2H, VT-4B5, DOOS: DST-7000S Cu:SY SCR20S, VT-4B3, VT-4B3C, DOOS: DST-7000S			
5	Metal Base Thickness	0.4-3.2mm	0.4mm-3.2mm			
6	Insulation Layer Thickness	50-150um	50-200um			
7	Max Working Panel	600mm × 500mm	730mm × 550mm			
8	Heat Conductivity	0.5W/mK-4.9W/mK	1W/mK、2W/mK、3W/mK、4W/mK、8W/mK			
9	Hi-Voltage Test (vary according to minimum distance between trace and board edge)(VDC)	0.3mm: Voltage Resistance DC 600V/50UA 0.5mm: Voltage Resistance DC 1000V/50UA 1.0mm: Voltage Resistance DC 1500V/50UA	0.3mm: Voltage Resistance DC 600V/50UA 0.5mm: Voltage Resistance DC 1000V/50UA 1.0mm: Voltage Resistance DC 1500V/50UA			
10	Breakdown Voltage (per different material type) (VAC) Ramp up 500V/S	4.0Kvac/4mil dielectric thickness	3.0Kvac/3mil dielectric thickness 4.0Kvac/4mil dielectric thickness			

# 5. Introduction to UGPCB Metal Substrate Capabilities



No.	ltem	MCPCB Capability			
NO.	item	Mass Production	Sample/Development		
11	Inner Layer Trace Width/Space	Min 0.1/0.1mm	Min 0.075/0.075mm		
12	Outer Layer Trace Width/Space	Min 0.1/0.1mm	Min 0.075/0.075mm		
13	Layer Registration	±0.05mm	±0.025mm		
14	Copper Foil Thickness	HOZ,1OZ,2OZ, 3OZ,4OZ	HOZ,1OZ,2OZ, 3OZ,4OZ,5OZ		
15	Min Finished Hole Diameter	0.70mm (≥Board Thickness)	0.60mm(≥Board Thickness)		
16	Finished Hole Size Tolerance	NPTH: ±0.05mm PTH: ±0.075mm	NPTH:±0.05mm PTH:±0.075mm		
17	Hole Position Accuracy(Compare with CAD)	±0.075mm	±0.05mm		
18	PTH Wall Copper Thickness	≥20um	≥20-35um		
19	Min Solder Mask Opening	0.075mm larger than hole per side	0.05mm larger than hole per side		
20	Min Gap between trace and SM opening	0.05mm	0.05mm		

## 6. Introduction to the Customer Base for UGPCB Metal Substrates





















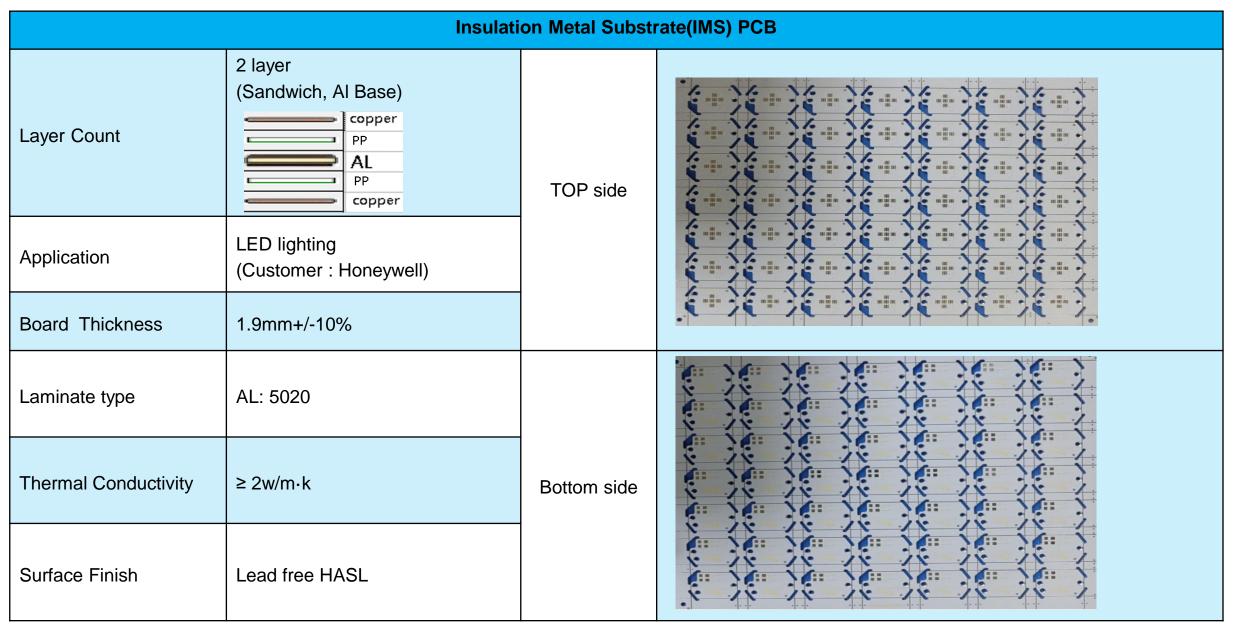


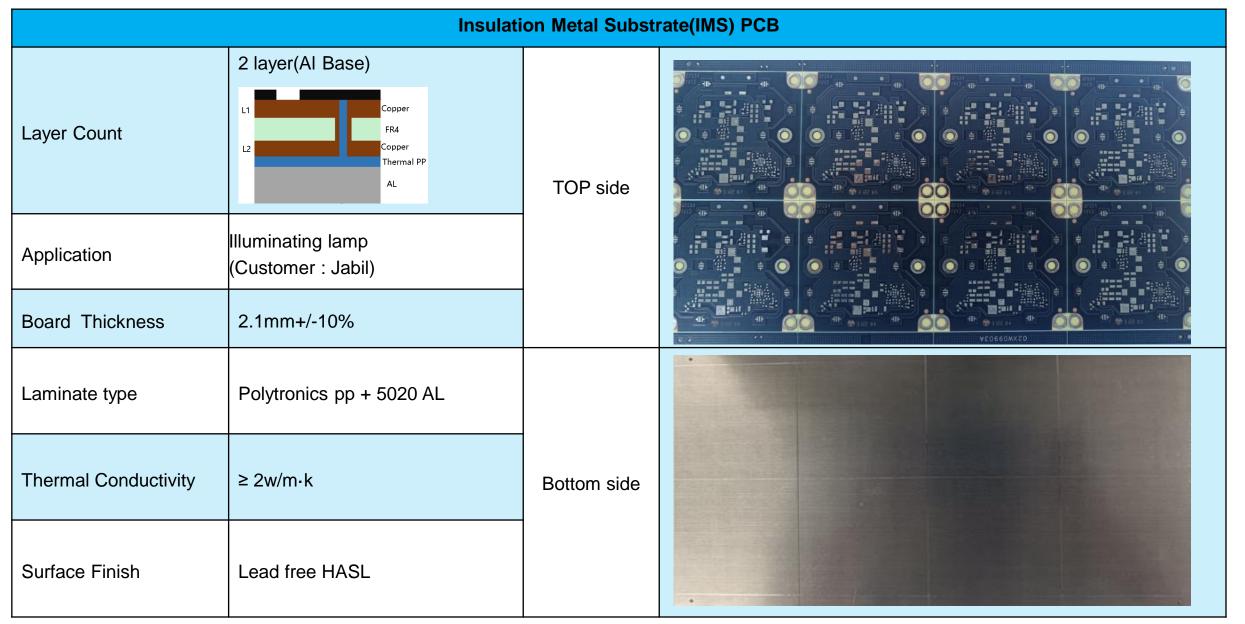






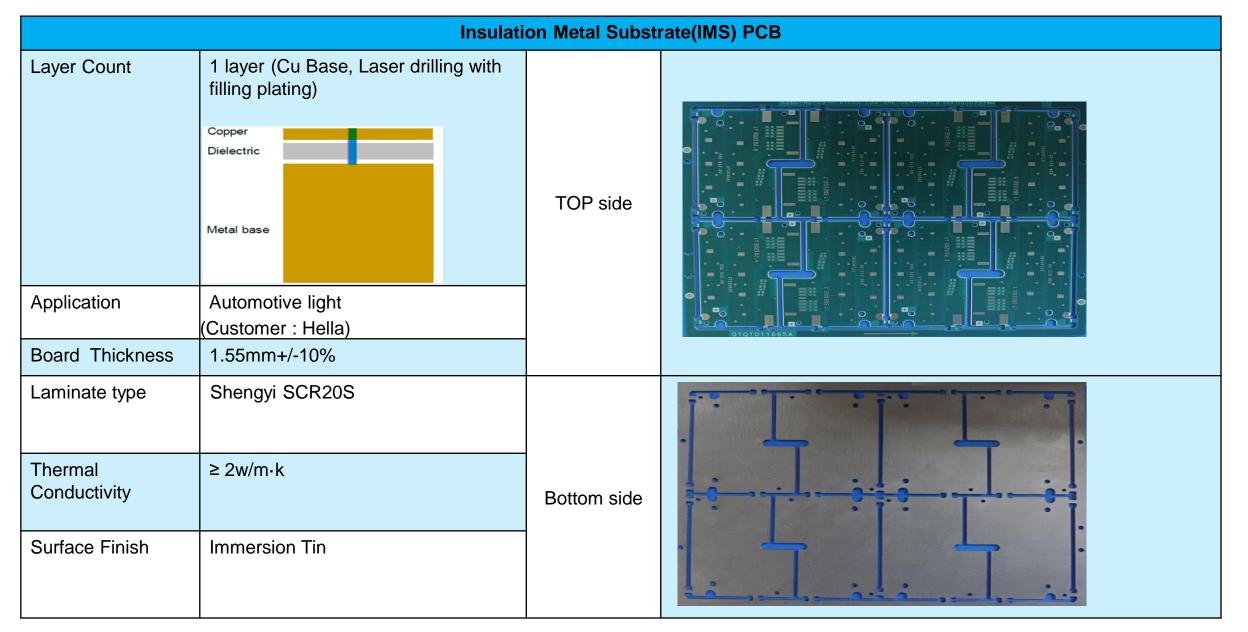
	Insulation Metal Substrate(IMS) PCB					
Layer Count	1 Layer, Al Base					
Application	Automotive lighting (Customer : Metasystem)	TOP SIDE				
Board Thickness	1.6mm+/-10% Al substrate 1.45mm					
Laminate type	Shengyi SAR20H			•		
Thermal Conductivity	≥ 2w/m·k					
Surface Finish	Lead free HASL	Bottom side				

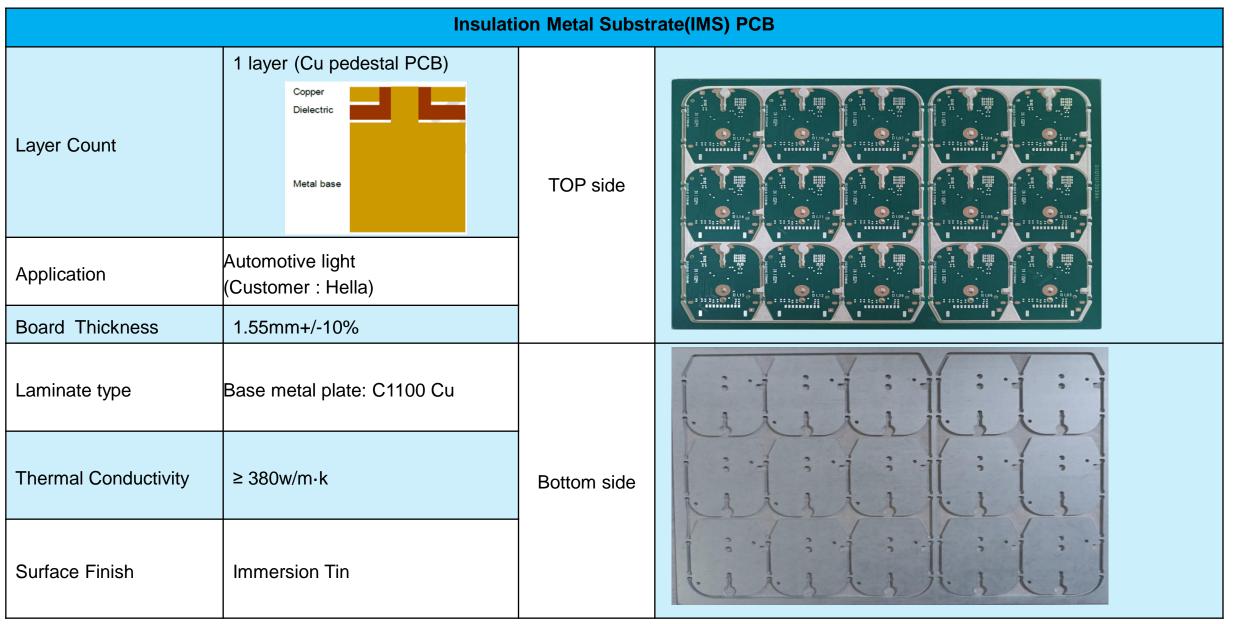






	Insulation Metal Substrate(IMS) PCB					
Layer Count	1 layer(Cu Base)	TOP side				
Application	Automotive light (Customer : Hella)					
Board Thickness	1.55mm+/-10%					
Laminate type	Shengyi SCR20S					
Thermal Conductivity	≥ 2w/m·k	Bottom side				
Surface Finish	ENIG					







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